



US00D685462S

(12) **United States Design Patent**
Lang et al.

(10) **Patent No.:** **US D685,462 S**

(45) **Date of Patent:** **** Jul. 2, 2013**

(54) **BREATHING MASK**

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(73) Assignee: **RedMed R&D Germany GmbH**, Martinsried (DE)

(**) Term: **14 Years**

(21) Appl. No.: **29/347,618**

(22) Filed: **Mar. 16, 2010**

Related U.S. Application Data

(60) Continuation of application No. 29/311,143, filed on Dec. 31, 2008, now Pat. No. Des. 614,762, which is a continuation of application No. 29/290,110, filed on Oct. 23, 2007, now Pat. No. Des. 585,982, which is a continuation of application No. 29/239,063, filed on Sep. 27, 2005, now Pat. No. Des. 572,816, which is a division of application No. 29/219,617, filed on Dec. 21, 2004, now Pat. No. Des. 515,698, which is a division of application No. 29/190,511, filed on Sep. 23, 2003, now Pat. No. Des. 502,260, which is a division of application No. 29/163,978, filed on Jul. 17, 2002, now Pat. No. Des. 484,237.

(30) **Foreign Application Priority Data**

Jan. 17, 2002 (DE) 40200458

(51) **LOC (9) Cl.** **29-02**

(52) **U.S. Cl.**
USPC **D24/110.1**

(58) **Field of Classification Search**
USPC D24/110, 110.1, 110.4, 110.5, 110.6;
128/205.25, 206.13, 206.14, 206.25, 206.28,
128/206.26, 206.23, 206.18, 207.11, 207.13
See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a breathing mask, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a breathing mask according to our design;

FIG. 2 is a front view thereof;

FIG. 3 is a rear view thereof;

FIG. 4 is a right side view thereof;

FIG. 5 is a left side view thereof;

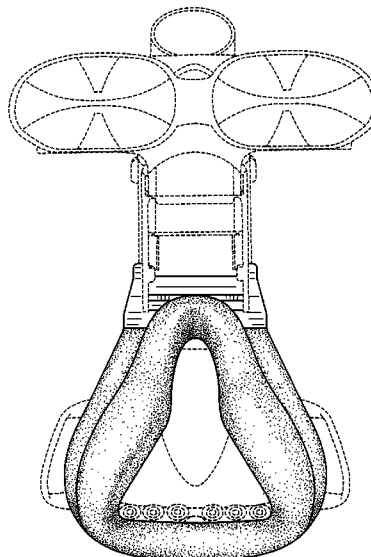
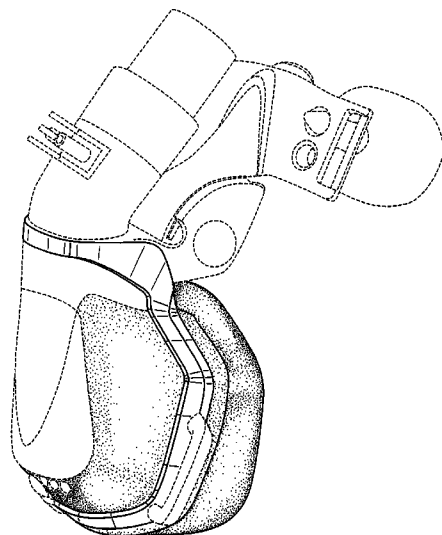
FIG. 6 is a top view thereof; and

FIG. 7 is a bottom view thereof.

The broken lines showing environment or structure of the breathing mask are for illustrative purposes only and form no part of the claimed design.

The stippling represents a contrast in material.

1 Claim, 7 Drawing Sheets



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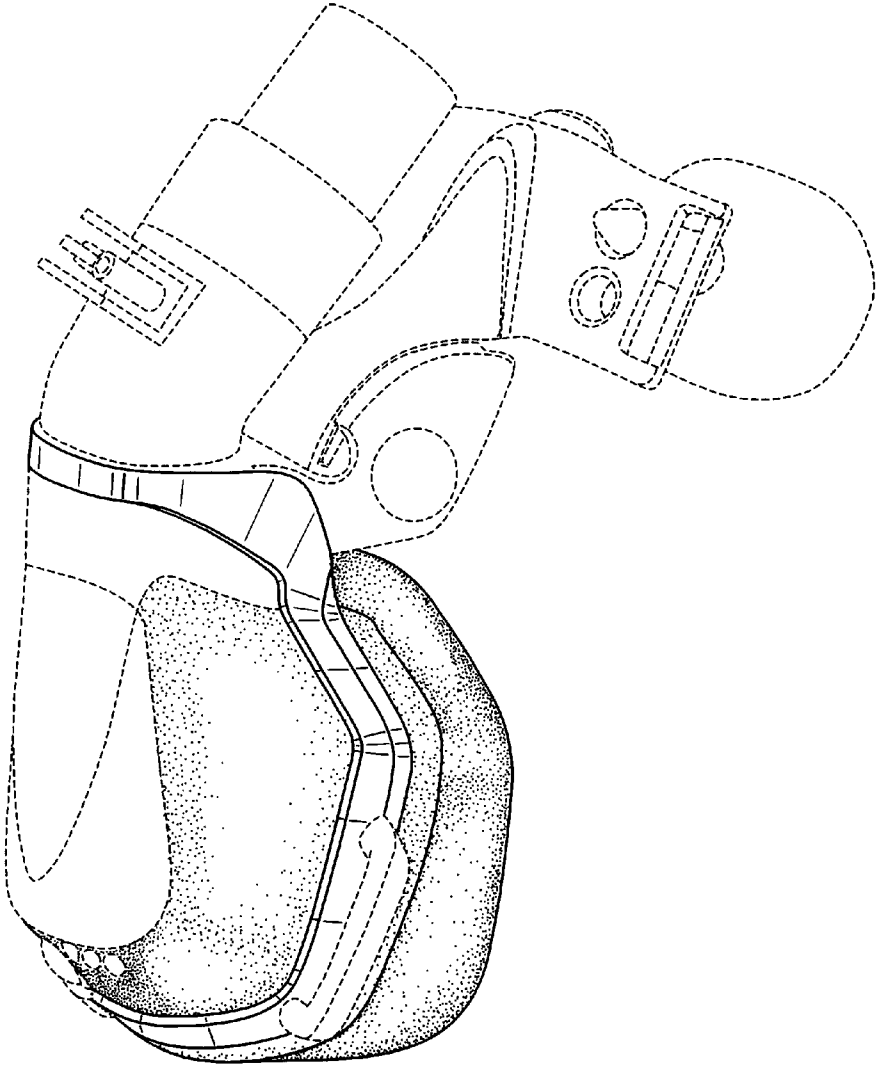


FIG. 1

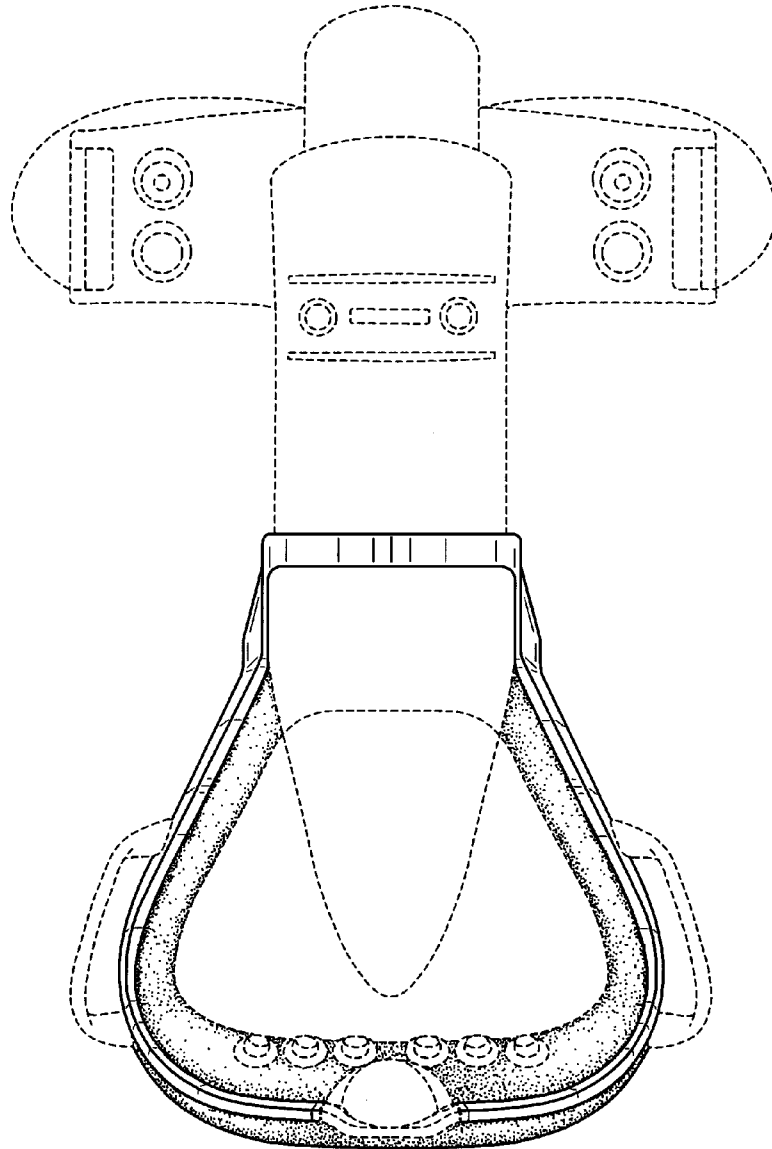


FIG. 2

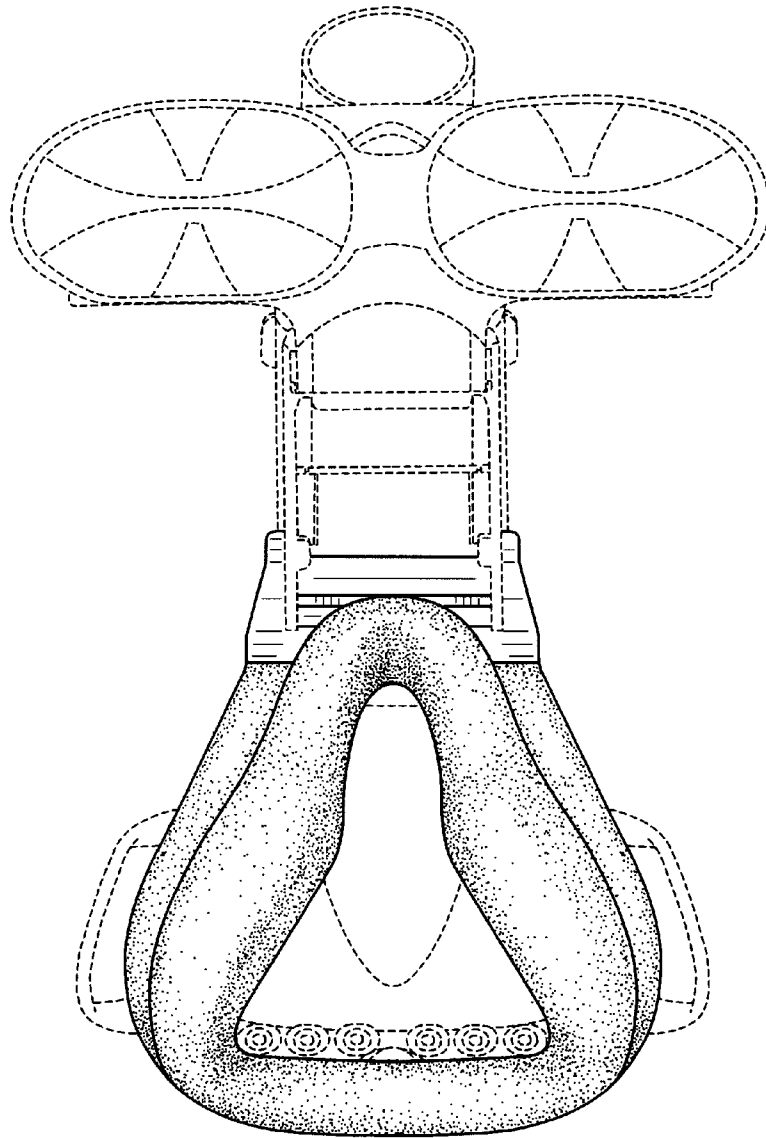


FIG. 3

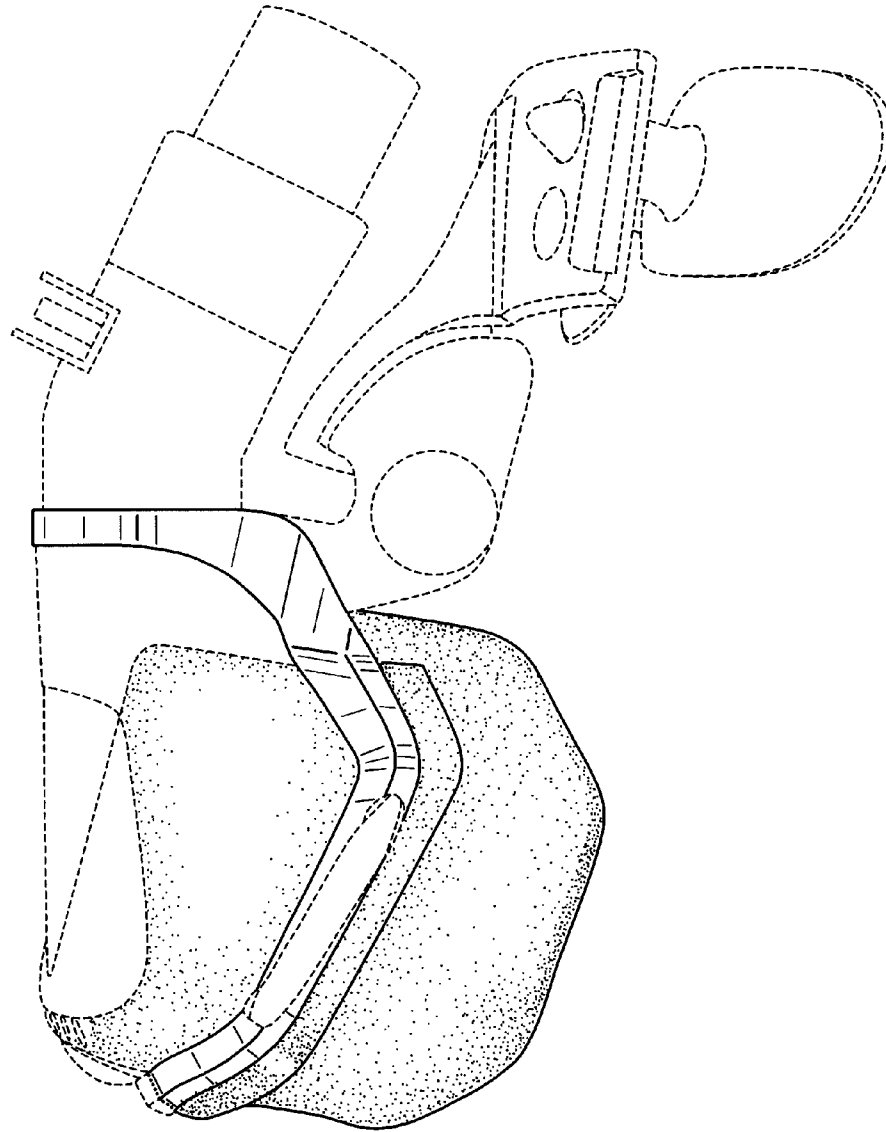


FIG. 4

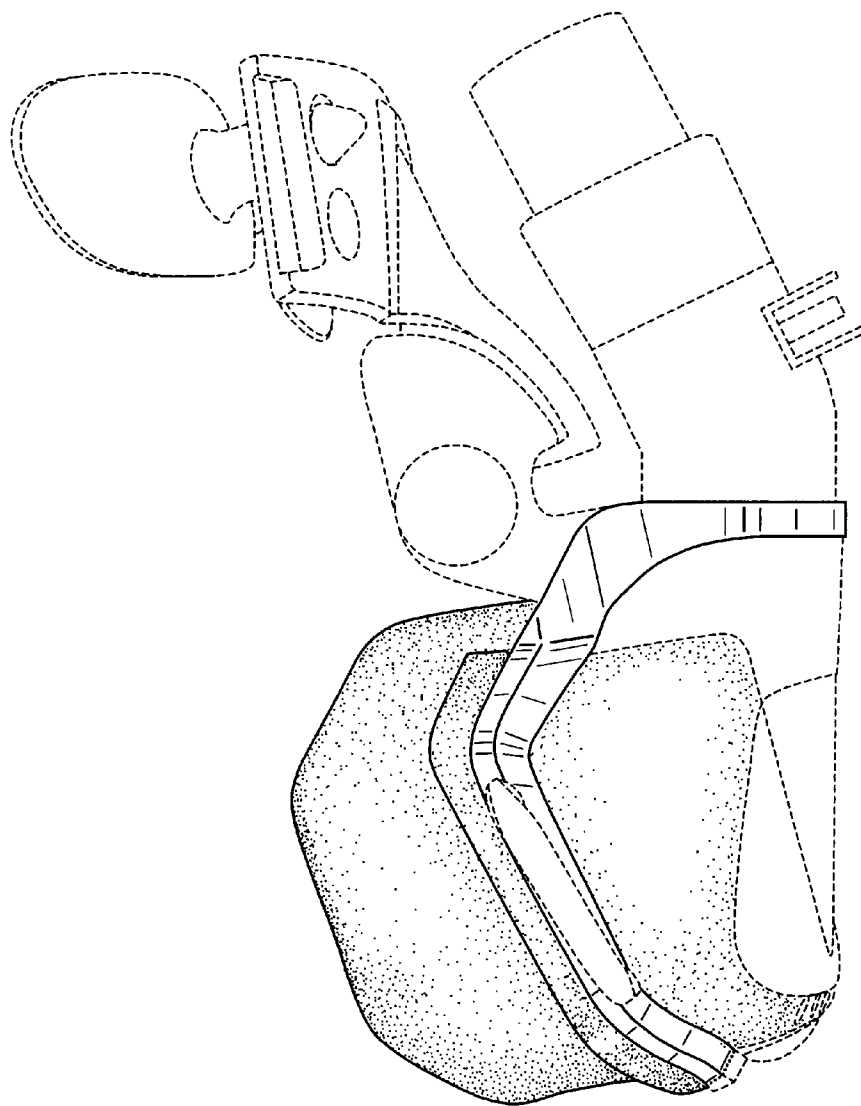


FIG. 5

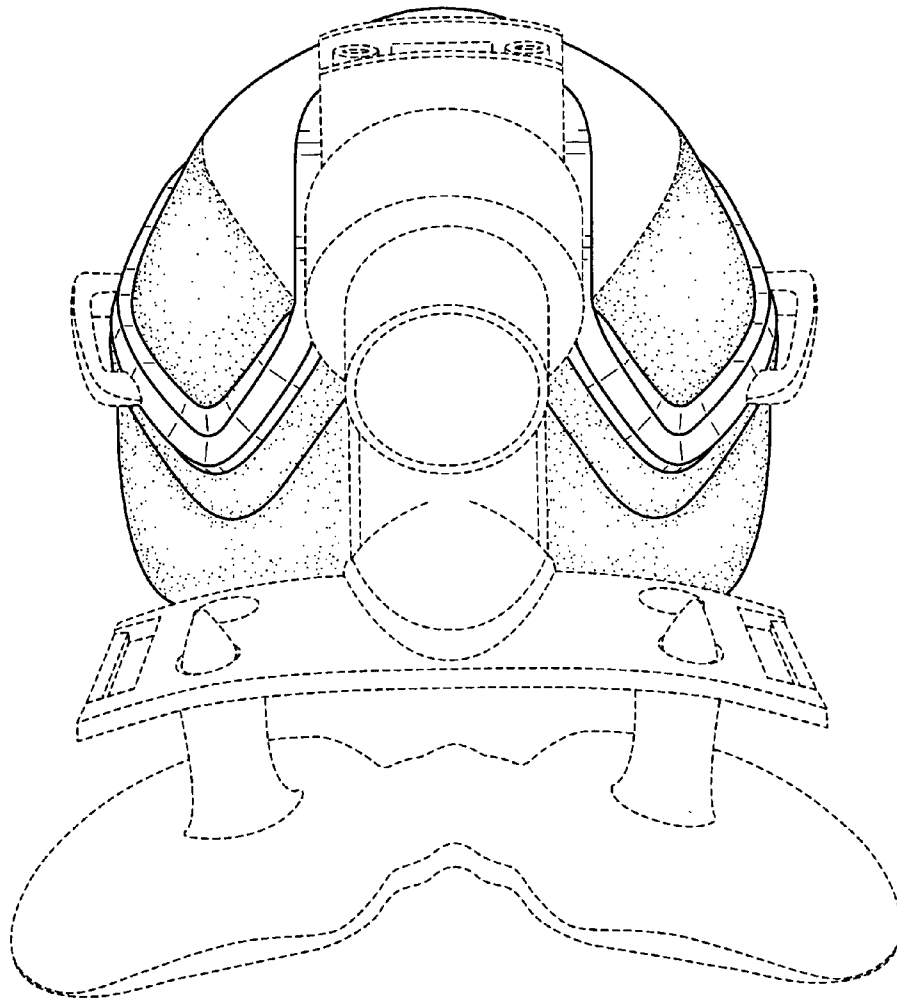


FIG. 6

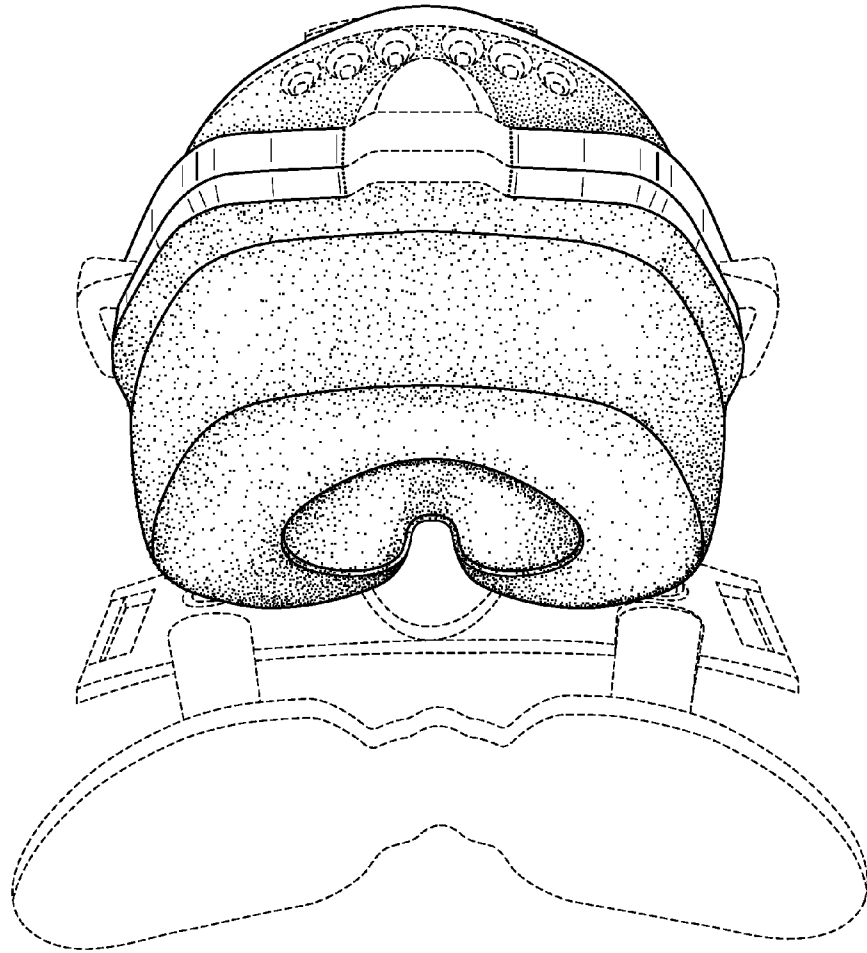


FIG. 7